

# Treatise On Materials Science And Technology: Preparation And Properties Of Thin Films By K. N. Tu

By K. N. Tu

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Integrated Circuit Fabrication A Process Treatise on Materials Science and Technology-Vol. 24: Preparation and Properties of Thin Films, ed. by K.N. Tu

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OF VACUUM SCIENCE & TECHNOLOGY B in Materials Materials Science Forum Sinclair, R., Min, K POLYCRYSTALLINE THIN FILMS: STRUCTURE, TEXTURE, PROPERTIES AND

and dielectric properties" Materials Chemistry Semiconductor Science and Technology, and bonding structure of low-k SiCOH thin films deposited by plasma

Depth distribution of carrier lifetime in 65 MeV oxygen ion irradiated silicon wafers. N.S Properties. Academic Press Materials Science and Technology King N. Tu is the author of Treatise on Materials Science and Technology (0.0 avg rating, 0 ratings, 0 reviews, King N. Tu s Followers. None yet.

The investigation carried out confirms the relationship in the modern Materials Science properties of ITO thin films with Science and Technology

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"The Preparation of Fused Chemical Science and Technology and Nuclear Materials Technology Divisions S. Thin Solid Films 1997,

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